

Client Reference: P-1841.000-US

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Re the Application of

SASELMANS et al.

Group Art Unit: 1651

Application No.: 10/814,822

Examiner: Unassigned

Filed: April 1, 2004

Confirmation No.: 5320

For: LITHOGRAPHIC APPARATUS, DEVICE MANUFACTURING METHOD AND DEVICE

MANUFACTURED THEREBY

September 9, 2004

INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents P. O. Box 1450 Alexandria, VA 22313-1450

Sir:

Pursuant to 37 C.F.R. 1.56, the attention of the Patent and Trademark Office is hereby directed to the following U.S. patent application(s):

Examiner's Initials	First Inventor	Application No.	Filing Date	Enclosed
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	DE SMIT (081468-0309173)	10/820,227	04/08/2004	☑ Specification☑ Drawings☑ Other: stamped receipt card
	DE SMIT (081468-0309978)	10/860,662	06/04/2004	 ✓ Specification ✓ Drawings ✓ Other: stamped receipt card
	DUINEVELD et al. (081468-0308101)	10/773,461	02/09/2004	☒ Specification☒ Drawings☒ Other: stamped receipt card
	FLAGELLO et al. (081468-0302644)	10/698,012	10/31/2003	☒ Specification☒ Drawings☒ Other: stamped receipt card
	DE SMIT et al. (081468-0306530)	10/705,804	11/12/2003	☒ Specification☒ Drawings☒ Other: stamped receipt card
	LOF et al. (081468-0306781)	10/705,805	11/12/2003	☒ Specification☒ Drawings☒ Other: stamped receipt card
	LOF et al. (081468-0306524)	10/705,783	11/12/2003	☒ Specification☒ Drawings☒ Other: stamped receipt

Examiner's Initials	First Inventor	Application No.	Filing Date	Enclosed
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P 0 9 2004	VAN SANTEN et al. (081468-0307331)	10/743,271	12/23/2003	 ☑ Specification ☑ Drawings ☑ Other: stamped receipt card
* TRADEMAN	MULKENS et al. (081468-0307333)	10/743,266	12/23/2003	☒ Specification☒ Drawings☒ Other: stamped receipt card
	DERKSEN et al. (081468-0306526)	10/705,785	11/12/2003	☒ Specification☒ Drawings☒ Other: stamped receipt card
	SIMON et al. (081468-0307087)	10/724,402	12/01/2003	☒ Specification☒ Drawings☒ Other: stamped receipt card
	BLEEKER (081468-0306527)	10/715,116	11/18/2003	✓ Specification✓ Drawings✓ Other: stamped receipt card
	STREEFKERK et al. (081468-0306882)	10/719,683	11/24/2003	☒ Specification☒ Drawings☒ Other: stamped receipt card
	LOF et al. (081468-0306525)	10/705,816	11/12/2003	☒ Specification☒ Drawings☒ Other: stamped receipt card
	DIERICHS (081468-0308270)	10/775,326	02/11/2004	☒ Specification☒ Drawings☒ Other: stamped receipt card
	LOF et al. (081468-0309957)	10/857,614	06/01/2004	☑ Specification☑ Drawings☑ Other: stamped receipt card
	SUWA et al. (Reissue Application of U.S. Patent No. 6,191,429 B1)	10/367,910	02/19/2003	☑ Specification☑ Drawings☐ Other: stamped receipt card
	BASELMANS et al. (081468-0309488)	10/835,856	05/03/2004	☒ Specification☒ Drawings☒ Other: stamped receipt card

^{*}The Examiner's initials adjacent a citation indicates he/she has considered the cited application relative to the subject application.

It is respectfully requested that these applications and the art cited therein during examination be expressly considered during the prosecution of this application and be made of record in this application. The identification of the above U.S. patent applications is not to be construed as a waiver of secrecy as to those applications now or upon issuance of the present application as a patent.

<u>PLEASE DO NOT PRINT</u> the above information on the patent which results from this application.

Consideration of each listed application is earnestly solicited since unpublished patent applications are contemplated as IDS material; see the exception in Rule 98(a)(2)(iii) and note the penultimate sentence of MPEP 609.

Further, in keeping with MPEP 609, subsec. C(2), 2nd para., line 10 to end of the paragraph (especially note lines 18-25) PLEASE <u>RETURN</u> A COPY OF <u>THIS LETTER</u> with the Examiner's initials adjacent each above listing so that applicant will know that each listed application has been considered as required by PTO policy.

Secondly, please consider each document which is listed on the attached Form PTO-1449 and return a copy of that form with the Examiner's initials adjacent each citation, a copy of each document enclosed except for any U.S. patents and published patent applications. It is respectfully requested that these documents listed on the Form PTO-1449 be expressly considered during the prosecution of this application, and that the documents be made of record therein and appear among the "References Cited" on any patent to issue therefrom.

This Information Disclosure Statement is being filed before the mailing date of the first Office Action on the merits in the present application. No certification or fee is required.

Respectfully Submitted,

PILLSBURY WINTHROP LLP

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U.S. PATEN	NT DO	CUMENTS	···	,						-		· · · · · · · · · · · · · · · · · · ·			
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Initials*	 	Number		MM/Y		(Family N		irst Inven	tor)	. ,	 	Clas	s	(if approp	oriate
	AR	3,573,975		04/19		DHAKA e					117	212		ļ	
	BR	3,648,587		03/19		STEVENS					95	44		ļ	
	CR	4,346,164	08/19		TABAREL					430	311		<u> </u>		
	DR	4,390,273		06/19		LOEBAC					355		125		
	ER	4,396,705		08/19		AKEYAMA et al.		al.			430	326		<u> </u>	
	FR	4,480,910		11/19		TAKANAS					355	30	30		
	GR	4,509,852		04/19		TABAREL						30		ļ	
	HR	5,040,020		08/19		RAUSCHENBACH et al.			355 359	53		ļ			
	IR	5,121,256		06/19		CORLE e	t al.					664			
	JR	5,610,683		03/1997 02/1998		TAKAHAS					355	53			
	KR	5,715,039				FUKUDA et al.				355	53				
	LR	5,825,043		10/19	98	SUWA BATCHELDER				250	548				
		5,900,354		05/19	99					430	395		<u> </u>		
	NR	6,191,429		02/20	01	SUWA					250	548			
FOREIGN F	ATEN	T DOCUMENTS			_							English At	ostract	Translation	on
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	SR	DD 224448	07/198		GERM		HESSE	et al.				<u> </u>	X	<u> </u>	+
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	VR	JP 62-065326	03/198		JAPAI		MORIUC					X	+	<u> </u>	+
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		JP 06-124873	05/199		JAPAI		TAKAHA					X	<u> </u>	X	<u>Ļ</u>
OTHER (Inc		M. SWITKES et December 17, 2	al., "Imi							b, Orlando 20	001-1,				+
	CCR	M. SWITKES et No. 6, November	al., "Imi	mersio	n Litho	graphy at 1	157 nm", .	J. Vac. S	ci. Te	chnol. B., Vol	. 19,		+		+
	DDR	M. SWITKES et September 4, 20	al., "lmı					ne 50 nm	Node	", 157 Anvers	s-1,		1		+
Examiner		1-05:0:001 -1 20					D	ate Consi	dered	·		<u> </u>		1	
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FORM PTO-1449 (modified) To: U.S. Department of Commerce (PW FORM PAT-1449) Patent and Trademark Office							Atty. Dkt. No.	M#		Clien	t Ref	•	
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U.S. PATEN	T DOC	UMENTS											
Examiner's		Document		Date		Name			Clas			Filing C)ate
Initials*		Number		MM/Y	YYY	(Family Na	me of First	Inventor)		Class	<u> </u>	(if approp	riate)
	AR	6,560,032		05/20	03	HATANO			359	656			
	BR	6,600,547		07/20	03	WATSON 6	et al.		<u> </u>			<u> </u>	
	CR	6,603,130		08/20	03	BISSCHOP	S et al.		250	492.1	492.1		
	DR	6,633,365	ŀ	10/20	03	SUENAGA			355	53			
	ER	2002/0163629		11/20	02	SWITKES 6	et al.		355	53			
	FR	2003/0123040		07/20	03	ALMOGY	×		355	69			
	GR	2003/0174408		09/20	03	ROSTALSK	(I et al.		359	642			
	HR	2004/0000627 A1		01/20	04	SCHUSTER	STER						
	IR_	2004/0021844 A1		02/20	04	SUENAGA LIN							
	JR	2004/0075895 A1		04/20	04			359		380			
	KR	2004/0109237 A1		06/2004 EPPLE et		EPPLE et a	l.						
FOREIGN P	ATENT	DOCUMENTS								English Ab	stract	Translatio	n n
,		Document	Date		Country	у	Inventor N	ame				Readily Available	
		Number	MM/Y	1/YYYY						March 1		7	
										Enclosed	No	Enclosed	No
	LR	JP 07-220990	08/19	95	JAPAN		FUKUDA	et al.		Х			
	MR	JP 10-228661	08/19	98 .	JAPAN		KUROKAV		X				
	NR	JP 10-255319 .	09/19	98	JAPAN		SUENAGA et al.			Х			
	OR	JP 10-303114	11/19	98 ,	JAPAN		SUWA			Х		X	
	PR	JP 10-340846	12/19	98 .	JAPAN		KUDO			X		X	
	QR	JP 2001-091849	04/20	01 .	JAPAN		AIZAKI et	al.		Х			
	RR	JP 07-132262	05/19	95	Japan		HIRAKAW	'A et al.		Х			
	SR	JP 58-202448	11/19	83 .	Japan		KAWAMU	RA et al.		Х			
	TR	WO 2004/019128	03/20	04	PCT		OMURA e	t al.		Х		Х	
	UR	WO 03/077037	09/200	03	PCT		ROSTALS			X		X	
	VR	WO 03/077036	09/200	03	PCT		SCHUSTE	R		X			
OTHER (Inc	cluding	in this order Author	, Title,	Perio	odical I	Name, Date	e, Pertinen	t Pages, etc.)			<u> </u>		
	WR	B.J. LIN, "Drivers, Pro September 2002	spects	and (Challen	ges for Imm	ersion Litho	ography", TSMC, Inc.	1				
	XR	B.J. LIN, "Proximity Property No. 11B, April 1978, p			gh Liqu	uid", IBM Ted	chnical Disc	losure Bulletin, Vol.2	20,				
	YR	B.J. LIN, "The Paths T Optical/Laser Microlith	Γο Subl	half-M			ithography'	, SPIE Vol. 922,					
	ZR	G.W.W. STEVENS, "I Technology, August 1	Reducti	ion of	Waste	Resulting fr	om Mask D	efects", Solid State					
	AAR	S. OWA et al., "Immer Microlithography 2003	rsion Li	ithogr	aphy; it	s potential p	erformance	and issues", SPIE					
	BBR	S. OWA et al., "Advan (2003)					on Lithogra	phy", Proc. SPIE 504	10				\Box
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muais	AR	6,236,634 B1		05/2001		(Family Nar LEE et al.	ne of First	ın	ventor)		369	112	•	(п арргорі	nate
	BR	2002/0020821 A1		02/2002	_	VAN SANT	TEN et al	-			250	492		 	
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	IR	WO 2004/053952 A1	06/20	004		PCT	MAGOME	e	t al.			Х			
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OTHER (In	cludir	ng in this order Author,													
_	RR	Nikon Precision Europe 2003													
	SR	H. KAWATA et al., "Op Greater than Unity", Mi	croele	ectronic En	gine	eering 9 (19	89), pp. 31	-3	6						_
	TR	J.A. HOFFNAGLE et al									ıy",				
	UR	J. Vac. Sci. Technol. B. B.W. SMITH et al., "Imi									_		 	1	+
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	VR	H. KAWATA et al., "Fai													
		Lithography with an Oil	Imme	ersion Lens	s", J	lpn. J. Appl.	Phys. Vol.	. 3	1 (1992), _I	op. 4174-	.				
	WR	G. OWEN et al., "1/8µn November/December 1					Sci. Techno	ol.	B., Vol. 10), No. 6,	T	-			T
	XR	H. HOGAN, "New Semi Photonics Technology	icond	uctor Litho	gra	phy Makes a		PH	HOTONICS	SPECT	RA,				T
	YR	S. OWA and N. NAGAS Lithography", NGL Wor	SAKA	, "Potentia	l Pe	rformance a	ınd Feasib		•	rsion					T
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FORM PTO-1449 (modified) To: U.S. Department of Commerce (PW FORM PAT-1449) Patent and Trademark Office							M#			Clien	t Ref	•	
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Examiner's		Document		Date	Name				Class	Sub		Filing D	ate
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	•	2004/0119954		06/2004	KAWAS	HIMA et al.			355	30			
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	QQR	S. OWA et al., "Update SEMATECH, Los Ange	on 19 les, J	93nm imme anuary 27-2	rsion expos 29, 2004, SI	ure tool", Lith	o Forum, Int	ernationa	ı			:	
	RRR	H. HATA, "The Develop SEMATECH, Los Ange						ernationa					
	SSR	T. MATSUYAMA et al., 5377-65, March, 2004						ny 2004,					\dagger
	TTR	"Depth-of-Focus Enhar	re Bi	ent Using H	igh Refractiv	e Index Laye	r on the Ima	iging Laye	er",				
	UUR	A. SUZUKI, "Lithograpi 2004						, January	5,	-			
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